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AMENDMENTS TO THE CLAIMS

Please amend the claims as follows:

1. - 3. (Canceled).

4. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein the susceptor is made of a quartz material.

5. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein the groove has a polygonal configuration.

6. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein a bottom face of the groove has a curved configuration.

7. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein a bottom face of the groove includes an incline plane and a perpendicular plane.

8. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein the groove has a V-shaped configuration.

9. (Canceled)

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10. (Previously Presented) The vacuum deposition apparatus according to claim 4,

wherein the susceptor is in direct contact with the glass substrate when the glass substrate is

heated.

11. - 15. (Canceled)

16. (Previously Presented) The vacuum deposition apparatus according to claim 18,

wherein the susceptor is rectangular.

17. (Canceled)

18. (Currently Amended) A vacuum deposition apparatus having a process chamber,

comprising:

a susceptor having a recessed central portion provided with lift pins and raised perimeter

portions for heating a glass or quartz substrate, all four edgeseach raised perimeter portion of the

susceptor acting as a sliding portion on which to slide the glass or quartz substrate totoward a

stopped position by stopping pins placed on the sliding portion, the susceptor having a raised

perimeter portion structured to accommodate sliding of the glass substrate without incurring

contact of the glass or quartz substrate with a build up of vacuum deposited material on the

raised perimeter portions of the susceptor;

means for positioning the glass or quartz substrate into contact with the susceptor at a

non-parallel angle to a top surface of the susceptor and for permitting edges of the glass or quartz

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substrate to slide along a raised perimeter portion of the susceptor toward stopping pins until the

glass or quartz substrate is substantially parallel with the susceptor;

wherein theeach raised perimeter portion of the susceptor includes a groove formed in all

four edges of said raised perimeter portion at a location of the stopping pins to receive vacuum

deposited material and thereby minimize formation by the vacuum deposited material of a film

on the raised perimeter portion of the susceptor, and

wherein a length of said raised perimeter portion, measured from a stopper pin to a contact

position of the glass or quartz substrate on the top surface of the susceptorsaid groove, to the

recessed center portion of the susceptor is about 10 mm to stabilize transfer minimize breakage

of the glass or quartz substrate by preventing a severe bend of the glass or quartz substrate during

transfer of the glass or quartz substrate-to the susceptor.

19. (New) A method of stabilizing transfer of a glass or quartz substrate to a susceptor

for heating the glass or quartz substrate,

wherein edge portions of the susceptor are adapted to permit sliding of the glass or quartz

substrate to a stopped position by stopping pins placed on the edge portions, the susceptor having

a raised perimeter portion structured to accommodate sliding of the glass substrate without

incurring contact of the glass or quartz substrate with a build up of vacuum deposited material on

the raised perimeter portion of the susceptor;

wherein the vacuum deposition apparatus includes a means for positioning the glass or

quartz substrate into contact with the susceptor at a non-parallel angle to a top surface of the

susceptor and for permitting edges of the glass or quartz substrate to slide along a portion of the

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susceptor toward stopping pins until the glass or quartz substrate is substantially parallel with the

susceptor,

wherein the susceptor includes a groove formed in all four edges of said raised perimeter

portion at a location of the stopping pins to receive vacuum deposited material and thereby

minimize formation by the vacuum deposited material of a film on the raised perimeter portion

of the susceptor, the method comprising:

making a length of said raised perimeter portion, measured from a stopper pin to a

contact position of the glass or quartz substrate on the top surface of the susceptor to be about

10mm to stabilize the transfer of the glass or quartz substrate to the susceptor.